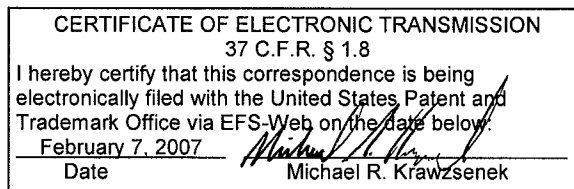


PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Title: HIGH INDEX AND HIGH IMPACT RESISTANT
POLYTHIOURETHANE/UREA MATERIAL, METHOD OF
MANUFACTURING SAME AND ITS USE IN THE OPTICAL FIELD

Appl. No.: 09/992,054
Applicants: Adileh *et al.*
Filed: November 14, 2001
TC/A.U.: 1711
Examiner: Sergeant, Rabon A
Docket No.: ESSR:058US
Customer No.: 32425
Confirmation No. 4850



RESPONSE TO THE OFFICE ACTION MAILED ON NOVEMBER 8, 2006

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant submits this Response to the Office Action mailed on November 8, 2006 ("the Action"), for the above-referenced case. It is believed that no fee is due for filing this Response. Should any fees under 37 C.F.R. §§ 1.16 to 1.21 be required for any reason relating to this document, the Commissioner is authorized to deduct said fees from or to Fulbright & Jaworski Deposit Account No. 50-1212/ESSR:058US.

Amendments to the Claims are reflected in the listing of claims which begins on page 2.

Remarks/Arguments begin on page 9.